Review of: "This field becomes Especially, nanoelectronic lithography has great potential to set new standards for making miniature, low-cost, and light-weight optics that can be used in many fields of applications."

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Potential competing interests: No potential competing interests to declare.

Electron beam nanolithography provides the possibility of precise control of nanostructure features that form the basis of various device technologies. The ability to produce large micro- and nanostructures on non-planar surfaces is important for many applications such as optics, optoelectronics, nanophotonics, imaging technology, NEMS, and microfluidics.

Lithography in nanoelectronics is currently considered as a promising low-cost, high-throughput, and high-resolution nanopatterning method, especially for the production of large-scale small/nanopatterns and complex 3D structures, as well as the aspect. The above characteristics of the ratio regarding these outstanding advantages have also resulted. This field becomes Especially, nanoelectronic lithography has great potential to set new standards for making miniature, low-cost, and light-weight optics that can be used in many fields of applications.

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